

Cyclic voltammetry behavior modelling of fabricated nanostructured Ni(OH)₂ electrode using
artificial neural network for supercapacitor application

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Table S1. Scan rate 10 mVs⁻¹

W1	W2	b1	b2
-4.5162 -1.4385;	-2.9146 -0.38871 3.314	6.6319;	1.3222
-2.5621 -3.1891;	1.8786 -0.23065 -	4.3656;	
-6.1071 -4.8568;	0.59409 0.40018 -	2.6247;	
7.2817 5.2218;	1.3675 0.47605 0.67109	-2.1163;	
0.71032 -4.3541;		-0.50645;	
1.3998 -4.2263;		0.44138;	
11.186 1.7927;		0.17315;	
-5.2632 2.4694;		-3.8221;	
-4.4594 1.1643;		-3.0891;	
2.3579 2.5217		5.1294	



